

AP/HMW



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re the Application of: **Shun-ichi FUKUYAMA et al.**

Group Art Unit: **2813**

Serial No.: **10/630,716**

Examiner: **Stephen W. Smoot**

Filed: **July 31, 2003**

Confirmation No.: **9374**

For: **SEMICONDUCTOR DEVICE USING LOW-K MATERIAL AS  
INTERLAYER INSULATING FILM AND ITS MANUFACTURE  
METHOD**

Attorney Docket Number: **030860**  
Customer Number: **38834**

**SECOND AMENDMENT AFTER FINAL REJECTION**

**MAIL STOP AF**

Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

Date: May 11, 2005

Sir:

This paper is filed in response to the Advisory Action dated May 4, 2005.

Amendments to the Claims begin on page 2 of this paper.

Remarks begin on page 6 of this paper.